



US00RE40436E

(19) **United States**
(12) **Reissued Patent**
Kothari et al.

(10) **Patent Number:** **US RE40,436 E**
(45) **Date of Reissued Patent:** **Jul. 15, 2008**

(54) **HERMETIC SEAL AND METHOD TO
CREATE THE SAME**

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(21) Appl. No.: **11/176,878**

(22) Filed: **Jul. 7, 2005**

Related U.S. Patent Documents

Reissue of:

(64) Patent No.: **6,589,625**
Issued: **Jul. 8, 2003**
Appl. No.: **09/921,196**
Filed: **Aug. 1, 2001**

(51) **Int. Cl.**
B32B 3/10 (2006.01)

(52) **U.S. Cl.** **428/46; 428/49; 428/76;**
428/192; 428/355 R

(58) **Field of Classification Search** **428/46,**
428/49, 76, 192, 355 R; 96/154
See application file for complete search history.

(56) **References Cited**

U.S. PATENT DOCUMENTS

2,534,846	A	12/1950	Ambrose et al.	
3,439,973	A	4/1969	Paul et al.	
3,443,854	A	5/1969	Weiss	
3,653,741	A	4/1972	Marks	
3,656,836	A	4/1972	de Cremoux et al.	
3,704,806	A *	12/1972	Plachenov et al.	206/204
3,813,265	A	5/1974	Marks	
3,900,440	A *	8/1975	Ohara et al.	523/410
3,955,880	A	5/1976	Lierke	
4,036,360	A *	7/1977	Deffeyes	206/204
4,074,480	A *	2/1978	Burton	52/127.1
4,099,854	A	7/1978	Decker et al.	
4,228,437	A	10/1980	Shelton	

(Continued)

FOREIGN PATENT DOCUMENTS

EP	0 667 548	8/1995
JP	02-068513	3/1990
JP	03-199920	8/1991
WO	WO 97/17628	5/1997
WO	WO 95/30924	11/1997
WO	WO 99/52006 A3	10/1999
WO	WO 99/52006 A2	10/1999
WO	WO 03/007049 A1	1/2003

OTHER PUBLICATIONS

Office Action mailed Sep. 24, 2002 in U.S. App. No. 09/921, 196.

Akasaka, "Three-Dimensional IC Trends," Proceedings of IEEE, vol. 74, No. 12, pp. 1703-1714 (Dec. 1986).

Aratani et al., "Process and Design Considerations for Surface Micromachined Beams for a Tuneable Interferometer Array in Silicon," Proc. IEEE Microelectromechanical Workshop, Fort Lauderdale, FL, pp. 230-235 (Feb. 1993).

Aratani et al., "Surface Micromachined Tuneable Interferometer Array," Sensors and Actuators, pp. 17-23 (1994).

Conner, "Hybrid Color Display Using Optical Interference Filter Array," SID Digest, pp. 577-580 (1993).

Goossen et al., "Possible Display Applications of the Silicon Mechanical Anti-Reflection Switch," Society for Information Display (1994).

(Continued)

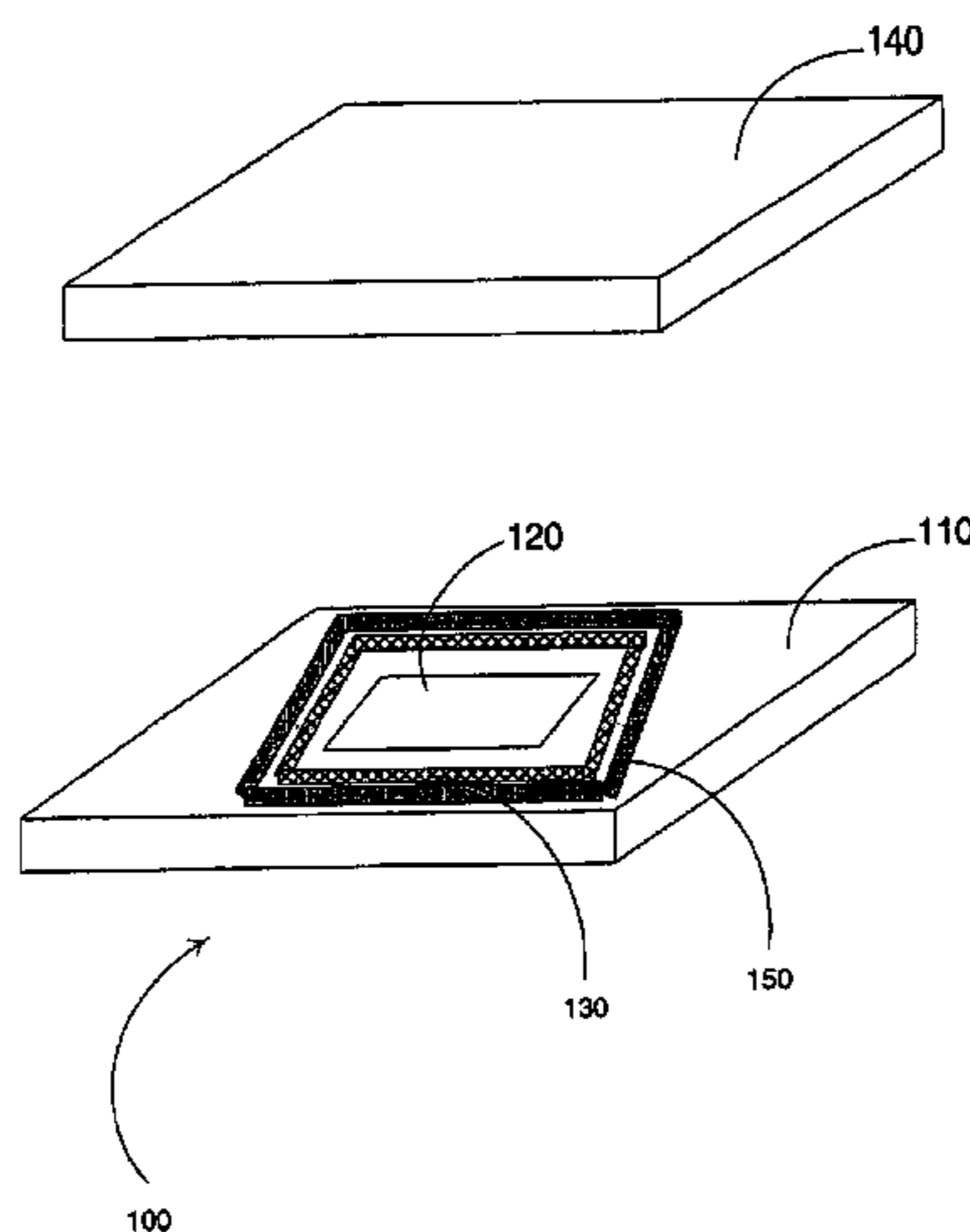
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(57) **ABSTRACT**

An electronic display screen is created by processing a mirror on a substrate glass. A back plate glass is then placed on top of the substrate glass and sealed to the back plate glass. A hermetic seal that includes an adhesive mixed with zeolites is disclosed. The hermetic seal can seal the back plate glass with the substrate glass. The application of the hermetic seal is not limited to the electronic display screen. Rather, the hermetic seal can be used to seal a variety of surfaces including metals, polymers, plastics, alloys, ceramics and the like.

26 Claims, 1 Drawing Sheet



US RE40,436 E

U.S. PATENT DOCUMENTS					
4,377,324	A	3/1983 Durand et al.	5,305,640	A	4/1994 Boysel et al.
4,389,096	A	6/1983 Horii et al.	5,311,360	A	5/1994 Bloom et al.
4,403,248	A	9/1983 Te Velde	5,312,513	A	5/1994 Florence et al.
4,431,691	A *	2/1984 Greenlee 428/34	5,323,002	A	6/1994 Sampsell et al.
4,441,791	A	4/1984 Hornbeck	5,325,116	A	6/1994 Sampsell
4,445,050	A	4/1984 Marks	5,327,286	A	7/1994 Sampsell et al.
4,482,213	A	11/1984 Piliavin et al.	5,331,454	A	7/1994 Hornbeck
4,500,171	A	2/1985 Penz et al.	5,339,116	A	8/1994 Urbanus et al.
4,519,676	A	5/1985 te Velde	5,365,283	A	11/1994 Doherty et al.
4,531,126	A	7/1985 Sadones	5,381,253	A	1/1995 Sharp et al.
4,552,806	A *	11/1985 Hayashi et al. 428/312.6	5,401,983	A	3/1995 Jokerst et al.
4,566,935	A	1/1986 Hornbeck	5,411,769	A	5/1995 Hornbeck
4,571,603	A	2/1986 Hornbeck et al.	5,444,566	A	8/1995 Gale et al.
4,596,992	A	6/1986 Hornbeck	5,446,479	A	8/1995 Thompson et al.
4,615,595	A	10/1986 Hornbeck	5,448,314	A	9/1995 Heimbuch et al.
4,662,746	A	5/1987 Hornbeck	5,452,024	A	9/1995 Sampsell
4,663,083	A	5/1987 Marks	5,454,906	A	10/1995 Baker et al.
4,681,403	A	7/1987 te Velde et al.	5,457,493	A	10/1995 Leddy et al.
4,710,732	A	12/1987 Hornbeck	5,457,566	A	10/1995 Sampsell et al.
4,748,366	A	5/1988 Taylor	5,459,602	A	10/1995 Sampsell
4,786,128	A	11/1988 Birnbach	5,459,610	A	10/1995 Bloom et al.
4,790,635	A	12/1988 Apsley	5,461,411	A	10/1995 Florence et al.
4,856,863	A	8/1989 Sampsell et al.	5,489,952	A	2/1996 Gove et al.
4,950,344	A *	8/1990 Glover et al. 156/109	5,497,172	A	3/1996 Doherty et al.
4,954,789	A	9/1990 Sampsell	5,497,197	A	3/1996 Gove et al.
4,956,619	A	9/1990 Hornbeck	5,499,062	A	3/1996 Urbanus
4,977,009	A *	12/1990 Anderson et al. 428/76	5,500,635	A	3/1996 Mott
4,982,184	A	1/1991 Kirkwood	5,500,761	A	3/1996 Goossen et al.
5,018,256	A	5/1991 Hornbeck	5,506,597	A	4/1996 Thompson et al.
5,018,258	A	5/1991 Hornbeck	5,515,076	A	5/1996 Thompson et al.
5,022,745	A	6/1991 Zayhowski et al.	5,517,347	A	5/1996 Sampsell
5,028,939	A	7/1991 Hornbeck et al.	5,523,803	A	6/1996 Urbanus et al.
5,037,173	A	8/1991 Sampsell et al.	5,526,051	A	6/1996 Gove et al.
5,044,736	A	9/1991 Jaskie et al.	5,526,172	A	6/1996 Kanack
5,061,049	A	10/1991 Hornbeck	5,526,688	A	6/1996 Boysel et al.
5,075,796	A	12/1991 Schildkraut et al.	5,535,047	A	7/1996 Hornbeck
5,078,479	A	1/1992 Vuilleumier	5,547,823	A *	8/1996 Murasawa et al. 430/531
5,079,544	A	1/1992 DeMond et al.	5,548,301	A	8/1996 Kornher et al.
5,083,857	A	1/1992 Hornbeck	5,550,373	A	8/1996 Cole et al.
5,095,375	A *	3/1992 Bolt 359/1	5,551,293	A	9/1996 Boysel et al.
5,096,279	A	3/1992 Hornbeck et al.	5,552,924	A	9/1996 Tregilgas
5,099,353	A	3/1992 Hornbeck	5,553,440	A *	9/1996 Bulger et al. 52/786.13
5,124,834	A	6/1992 Cusano et al.	5,559,358	A	9/1996 Burns et al.
5,142,405	A	8/1992 Hornbeck	5,563,398	A	10/1996 Sampsell
5,153,771	A	10/1992 Link et al.	5,567,334	A	10/1996 Baker et al.
5,162,787	A	11/1992 Thompson et al.	5,570,135	A	10/1996 Gove et al.
5,168,406	A	12/1992 Nelson	5,579,149	A	11/1996 Moret et al.
5,170,156	A	12/1992 DeMond et al.	5,581,272	A	12/1996 Conner et al.
5,172,262	A	12/1992 Hornbeck	5,583,688	A	12/1996 Hornbeck
5,179,274	A	1/1993 Sampsell	5,589,852	A	12/1996 Thompson et al.
5,192,395	A	3/1993 Boysel et al.	5,591,379	A *	1/1997 Shores 252/194
5,192,946	A	3/1993 Thompson et al.	5,597,736	A	1/1997 Sampsell
5,206,629	A	4/1993 DeMond et al.	5,600,383	A	2/1997 Hornbeck
5,212,582	A	5/1993 Nelson	5,602,671	A	2/1997 Hornbeck
5,214,419	A	5/1993 DeMond et al.	5,606,441	A	2/1997 Florence et al.
5,214,420	A	5/1993 Thompson et al.	5,608,468	A	3/1997 Gove et al.
5,216,537	A	6/1993 Hornbeck	5,610,438	A	3/1997 Wallace et al.
5,226,099	A	7/1993 Mignardi et al.	5,610,624	A	3/1997 Bhuvu
5,231,532	A	7/1993 Magel et al.	5,610,625	A	3/1997 Sampsell
5,233,385	A	8/1993 Sampsell	5,619,059	A	4/1997 Li et al.
5,233,456	A	8/1993 Nelson	5,619,365	A	4/1997 Rhoades et al.
5,233,459	A	8/1993 Bozler et al.	5,619,366	A	4/1997 Rhoades et al.
5,244,707	A *	9/1993 Shores 428/76	5,636,052	A	6/1997 Arney et al.
5,254,980	A	10/1993 Hendrix et al.	5,646,768	A	7/1997 Kaeiyama
5,272,473	A	12/1993 Thompson et al.	5,650,881	A	7/1997 Hornbeck
5,278,652	A	1/1994 Urbanus et al.	5,654,741	A	8/1997 Sampsell et al.
5,280,277	A	1/1994 Hornbeck	5,657,099	A	8/1997 Doherty et al.
5,287,096	A	2/1994 Thompson et al.	5,659,374	A	8/1997 Gale, Jr. et al.
5,296,950	A	3/1994 Lin et al.	5,665,997	A	9/1997 Weaver et al.
5,304,419	A *	4/1994 Shores 428/355 R	5,703,710	A	12/1997 Brinkman et al.
			5,710,656	A	1/1998 Goossen

5,739,945 A 4/1998 Tayebati
 5,745,193 A 4/1998 Urbanus et al.
 5,745,281 A 4/1998 Yi et al.
 5,771,116 A 6/1998 Miller et al.
 5,784,190 A 7/1998 Worley
 5,784,212 A 7/1998 Hornbeck
 5,815,141 A * 9/1998 Phares 345/173
 5,818,095 A 10/1998 Sampsell
 5,825,528 A 10/1998 Goosen
 5,835,255 A * 11/1998 Miles 359/291
 5,842,088 A 11/1998 Thompson
 5,853,662 A * 12/1998 Watanabe 422/40
 5,912,758 A 6/1999 Knipe et al.
 5,939,785 A 8/1999 Klonis et al.
 5,986,796 A * 11/1999 Miles 359/260
 6,028,690 A 2/2000 Carter et al.
 6,038,056 A 3/2000 Florence et al.
 6,040,937 A * 3/2000 Miles 359/291
 6,049,317 A 4/2000 Thompson
 6,055,090 A * 4/2000 Miles 359/291
 6,061,075 A 5/2000 Nelson et al.
 6,099,132 A 8/2000 Kaeriyama
 6,113,239 A 9/2000 Sampsell et al.
 6,147,790 A 11/2000 Meier et al.
 6,160,833 A 12/2000 Floyd et al.
 6,180,428 B1 1/2001 Peeters et al.
 6,201,633 B1 3/2001 Peeters et al.
 6,232,936 B1 5/2001 Gove et al.
 6,238,755 B1 * 5/2001 Harvey et al. 428/334
 6,282,010 B1 8/2001 Sulzbach et al.
 6,295,154 B1 9/2001 Laor et al.
 6,323,982 B1 11/2001 Hornbeck
 6,355,328 B1 * 3/2002 Baratuci et al. 428/68
 6,447,126 B1 9/2002 Hornbeck
 6,455,927 B1 9/2002 Glenn et al.
 6,465,355 B1 * 10/2002 Horsley
 6,466,358 B2 * 10/2002 Tew
 6,473,274 B1 * 10/2002 Maimone et al.
 6,480,177 B2 * 11/2002 Doherty et al.
 6,496,122 B2 * 12/2002 Sampsell
 6,545,335 B1 * 4/2003 Chua et al.
 6,548,908 B2 * 4/2003 Chua et al.
 6,549,338 B1 * 4/2003 Wolverton et al.
 6,552,840 B2 * 4/2003 Knipe
 6,582,789 B1 * 6/2003 Sumi 428/40.1
 6,600,201 B2 * 7/2003 Hartwell et al.
 6,606,175 B1 * 8/2003 Sampsell et al.
 6,625,047 B2 * 9/2003 Coleman, Jr.
 6,630,786 B2 * 10/2003 Cummings et al.
 6,643,069 B2 * 11/2003 Dewald
 6,650,455 B2 * 11/2003 Miles
 6,674,090 B1 * 1/2004 Chua et al.
 6,674,562 B1 * 1/2004 Miles
 6,680,792 B2 * 1/2004 Miles
 6,709,750 B1 * 3/2004 Pohlmann et al. 428/441
 6,710,908 B2 * 3/2004 Miles et al.
 6,775,174 B2 * 8/2004 Huffman et al.
 6,778,155 B2 * 8/2004 Doherty et al.
 6,822,628 B2 * 11/2004 Dunphy et al.
 6,859,218 B1 * 2/2005 Luman et al.
 6,862,022 B2 3/2005 Slupe
 6,862,029 B1 3/2005 D'Souza et al.
 6,867,896 B2 3/2005 Miles
 7,012,726 B1 3/2006 Miles
 7,012,732 B2 3/2006 Miles
 7,042,643 B2 5/2006 Miles
 7,119,945 B2 10/2006 Kothari et al.

7,123,216 B1 10/2006 Miles
 7,130,104 B2 10/2006 Cummings
 7,136,213 B2 11/2006 Chui
 7,138,984 B1 11/2006 Miles
 7,142,346 B2 11/2006 Chui et al.
 2001/0003487 A1 6/2001 Miles
 2002/0015215 A1 2/2002 Miles
 2002/0056898 A1 5/2002 Lopes et al.
 2002/0075555 A1 6/2002 Miles
 2002/0126364 A1 9/2002 Miles
 2002/0187254 A1 12/2002 Ghosh
 2003/0043157 A1 * 3/2003 Miles
 2003/0072070 A1 * 4/2003 Miles
 2003/0202266 A1 * 10/2003 Ring et al.
 2004/0051929 A1 * 3/2004 Sampsell et al.
 2004/0240032 A1 * 12/2004 Miles
 2005/0254155 A1 11/2005 Plamateer et al.
 2006/0066935 A1 3/2006 Cummings et al.
 2007/0097477 A1 5/2007 Miles

OTHER PUBLICATIONS

Goosen et al., "Silicon Modulator Based on Mechanically-Active Anti-Reflection Layer with 1Mbit/sec Capability for Fiber-in-the-Loop Applications," IEEE Photonics Technology Letters (Sep. 1994).
 Gosch, "West Germany Grabs the Lead in X-Ray Litography," Electronics, pp. 78-80 (Feb. 5, 1987).
 Howard et al., "Nanometer-Scale Fabrication Techniques," VLSI Electronics:Microstructure Science, vol. 5, pp. 145-153 and pp. 166-173 (1982).
 Jackson, "Classical Electrodynamics," John Wiley & Sons Inc., pp. 568-573.
 Jerman et al., "A Miniature Fabry-Perot Interferometer with a Corrugated Silicon Diaphragm Support," IEEE Electron Devices Society (1988).
 Johnson "Optical Scanners," Microwave Scanning Antennas, vol. 1, pp. 251-261 (1964).
 "Light over Matter," Circle No. 36 (Jun. 1993).
 Miles, "A New Reflective FPD Technology Using Interferometric Modulation," Society for Information Display '97 Digest, Session 7.3.
 Newsbreaks, "Quantum-trench devices might operate at terahertz frequencies," Laser Focus World (May 1993).
 Oliner et al., "Radiating Elements and Mutual Coupling," Microwave Scanning Antennas, vol. 2, pp. 134-194 (1966).
 Raley et al., "A Fabry-Perot Microinterferometer for Visible Wavelengths," IEEE Solid-State Sensor and Actuator Workshop, Hilton Head, SC (1992).
 Sperger et al., "High Performance Patterned All-Dielectric Interference Colour Filter for Display Applications," SID Digest, pp. 81-83 (1994).
 Stone, "Radiation and Optics, An Introduction to the Classical Theory," McGraw-Hill, pp. 340-343 (1963).
 Walker, et al., "Electron-beam-tunable Interference Filter Spatial Light Modulator," Optics Letters, vol. 13, No. 5, pp. 345-347 (May 1988).
 Winton, John M., "A novel way to capture solar energy," Chemical Week, pp. 17-18 (May 15, 1985).
 Wu, "Design of a Reflective Color LCD Using Optical Interference Reflectors," ASIA Display '95, pp. 929-931 (Oct. 16, 1995).

* cited by examiner

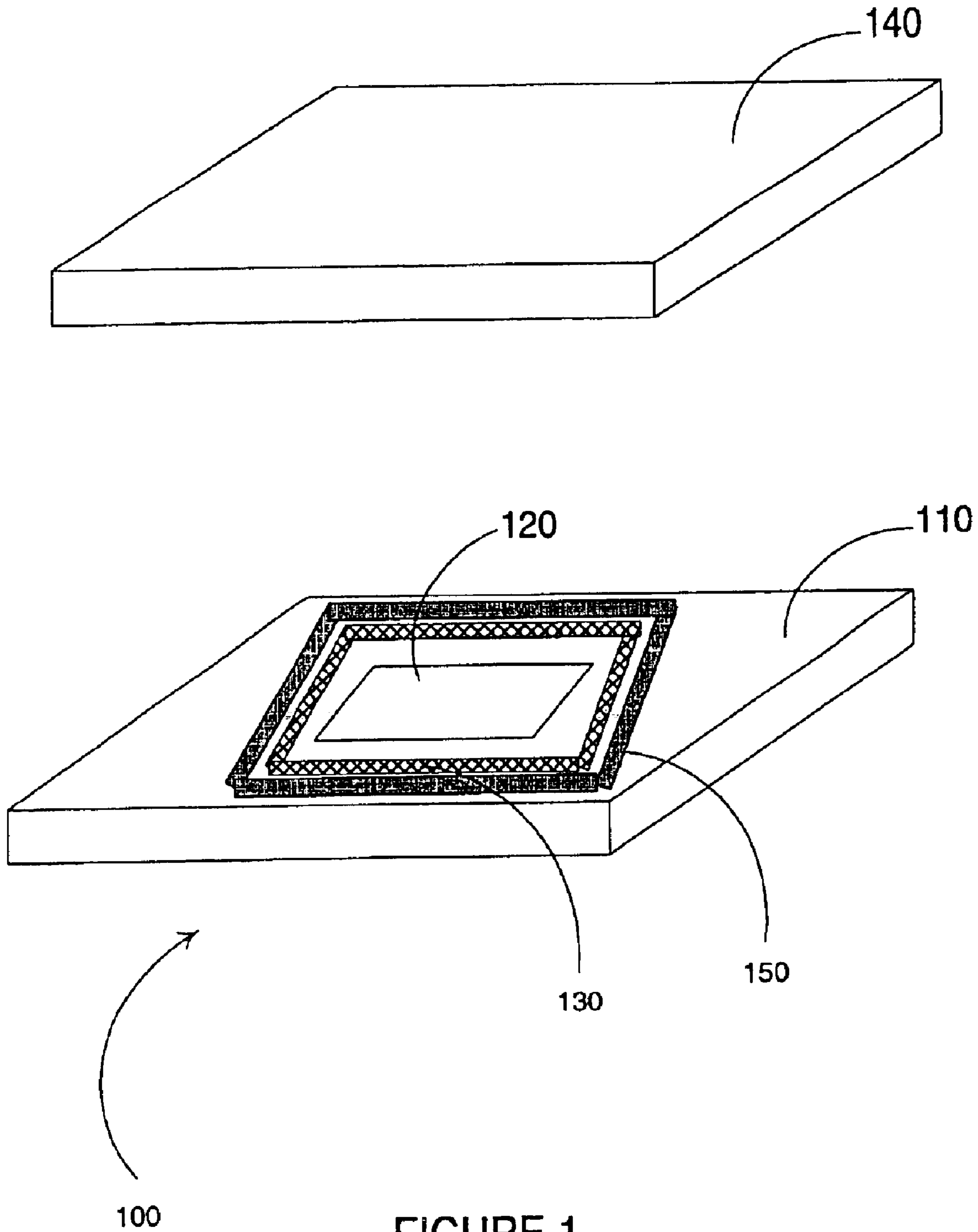


FIGURE 1

1

HERMETIC SEAL AND METHOD TO CREATE THE SAME

Matter enclosed in heavy brackets [] appears in the original patent but forms no part of this reissue specification; matter printed in italics indicates the additions made by reissue.

FIELD OF THE INVENTION

The present invention relates to a hermetic seal and methods to create the same. Specifically, a functional hermetic seal is disclosed that includes an adhesive mixed with an active component that can act as an absorbing filter on a molecular level.

BACKGROUND

To create an electronic display screen, a microelectromechanical systems (MEMS) based device such as a mirror is sandwiched between two glass plates: the back plate glass stand the substrate glass. The mirror is typically processed on the substrate glass. The back plate glass is then placed on top of the substrate glass to form the sandwich. The purpose of the back plate glass is to act as a viewing surface and to provide mechanical and environmental protection to the mirror. The sandwich is also referred to as the package.

The MEMS based device that is packaged in this manner is susceptible to problems associated with moisture and other harmful contaminants. The presence of moisture can cause stiction (static friction). The stiction can result because of the physical hydrogen bonding between the two glass surfaces in contact or because of the surface tension forces that result when the moisture between the two glass surfaces undergoes capillary condensation during the actuation of the MEMS based device. The presence of moisture can also cause electrochemical corrosion; for example, if the mirror includes an aluminum mirror.

The presence of harmful contaminants and moisture can pose a danger to the functioning of MEMS based device. For example, chlorine and moisture can combine to form an acidic environment that can be harmful to the MEMS based device. It is important that the package is moisture and contaminant free for the life of the device.

There are various channels by which water vapor or the contaminant can find its way inside the package. The moisture can enter the package from the environment in which the MEMS device is packaged. The moisture can permeate into the package from outside. The contaminant can be formed as a result of the outgassing of package components such as glass and polymers, especially at elevated temperatures.

In the prior art, to prevent the moisture and the contaminant from entering the package, the back plate glass and the substrate glass of the package are sealed to each other by using techniques such as welding and soldering, and by using o-rings. These prior art techniques are lacking in at least two respects. One, welding and soldering materials and o-rings occupy space. Real estate in MEMS based device packages is tight and there is a growing need for smaller form factors. Two, these prior art techniques do not eliminate the moisture and contaminants that are formed inside the package as a result of, for example, outgassing.

A simple technique to effectively seal two surfaces to each other that does not occupy additional real estate is desirable.

BRIEF DESCRIPTION OF THE DRAWING

The present invention is illustrated by way of example and not limitation in the figure of the accompanying drawing, in which:

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FIG. 1 illustrates an exemplary embodiment of package components that can be sealed with the hermetic seal of the present invention.

SUMMARY OF THE INVENTION

The hermetic seal including an adhesive mixed with an active component that can act as an absorbing filter on a molecular level is disclosed. The material can include a zeolite.

Additional features and advantages of the present invention will be apparent from the accompanying drawing and the detailed description that follows.

DETAILED DESCRIPTION

In the following descriptions for the purposes of explanation, numerous details are set forth such as examples of specific materials and methods in order to provide a thorough understanding of the present invention. It will be apparent, however, to one skilled in the art that these specific details are not required in order to practice the present invention. In other instances, well known materials and methods have not been described in detail in order to avoid unnecessarily obscuring the present invention.

In this description, a hermetic seal and, methods to create the same are disclosed. The hermetic seal includes an adhesive mixed with molecular sieves or zeolites. In one embodiment, the zeolites can include aluminosilicate-structured minerals such as sodium aluminosilicate. In another embodiment, the zeolites can include microporous silicate-structured minerals. It will be appreciated that active components other than zeolites that can act as absorbing filters on a molecular level can also be used. In one embodiment, the adhesive can include an adhesive with low outgassing numbers. In other embodiments, the adhesives can include adhesives with various outgassing numbers.

In one embodiment, the zeolites are mixed with the adhesive in a weight: ratio of 50:50. In other embodiments, the zeolites are mixed with the adhesive in various weight ratios. In one embodiment, the zeolites include zeolites in the powder form. In another embodiment, the zeolites include zeolites pellets. In yet another embodiment, the zeolites include zeolites beads.

The hermetic seal of the present invention can be applied as a bead between two surfaces to seal the two surfaces. The surfaces can include glass, metal, polymer, plastic, alloy or ceramic surfaces, or a combination thereof. The amount of bead that is applied can depend on the estimated amount of moisture or contaminant gases that will have to be removed from the package during the life of the package. This amount can be calculated by considering factors such as the amount of moisture/contamination that is present inside the package when the package is formed, the permeation rate of the adhesive, and the outgassing potential of the package components.

The zeolites can absorb water molecules at high temperatures. Zeolites of different pore sizes can be selected to absorb different contaminants. In one embodiment, the zeolites are selected to absorb contaminant molecules such as aromatic branched-chain hydrocarbons that have critical diameters of up to ten angstroms. In another embodiment, zeolites of pore sizes between two and three angstroms can be selected to absorb molecules of diameters less than two angstroms, namely hydrogen and moisture molecules. In yet another embodiment, zeolites of pore sizes of fifty angstroms are used to absorb nitrogen and carbon dioxide. mol-

ecules. In yet another embodiment, the hermetic seal can include a mixture of zeolites of various pore sizes.

The hermetic seal of the present invention can be constructed in a simple manner without using techniques such as welding and soldering, or by using o-rings. The bead can be applied through a simple in-line manufacturing process. The bead occupies a negligible amount of real estate and it does not significantly bulk up the package. The hermetic seal includes active components in the form of zeolites that can trap the moisture and other contaminant gases in their pores. The hermetic seal provides mechanical support to the MEMS based device package.

FIG. 1 illustrates an exemplary embodiment of package components that can be sealed with the hermetic seal of the present invention. The components **100** for the MEMS based device in the form of a flat panel display are shown. The components include the substrate glass **110**, the mirror **120**, the hermetic seal bead **130** and the back plate glass **140**. The mirror **120** is processed on the substrate glass **110**. The bead **130** is applied to the substrate glass **110** around the perimeter of the mirror **120**. The back plate glass **140** is placed on top of the substrate glass **110**. The substrate glass **110** and the back plate glass **140** are sealed together by the bead **130** to form the package **100**. In the ensuing description, the terms components **100** and package **100** are used interchangeably. Also, in the ensuing description, the terms bead **130** and hermetic seal **130** are used interchangeably.

The mirror **120** can be referred to as the MEMS based device or the MEMS structure. The package **100** can also be referred to as the glass sandwich. The package **100** formed by the components **100** can be a component of a flat panel display. An array of mirrors such as the mirror **120** can be processed on the substrate glass **110** to form the flat panel display. The back plate glass **140** serves as the viewing surface. The back plate glass **140** also serves a mechanical function because it prevents the user from touching the mirror **110**.

The mirror **120** can be processed through conventional semiconductor technology processes. The mirror **120** can include a metallic mirror such as an aluminum mirror. It will be appreciated that in addition to the mirror **120**, the package can include other display elements. It will be appreciated that clear plastic surfaces can replace the substrate glass **110** and the back plate glass **140**.

The bead **130** can be applied around the perimeter of the mirror **120**. For the embodiments in which the substrate glass **110** includes a plurality of mirrors **120**, the bead **130** can be applied around the perimeter of the plurality of mirrors **120**. In one embodiment, the bead **130** thickness is one hundred angstroms. In another embodiment, the bead **130** thickness is two hundred angstroms. In yet another embodiment, the bead **130** thickness is three hundred angstroms. In still other embodiments, beads **130** of various thicknesses that maintain a low form factor for the package **100** can be applied.

It will be appreciated that the application of the hermetic seal **130** of the present invention is not limited to the MEMS based products. The hermetic seal **130** can seal various surfaces of various devices and products. The hermetic seal **130** can seal surfaces including metals, plastics, polymers, ceramics, alloys and the like. The hermetic seal **130** of the present invention is ideal for the space critical environments because it occupies negligible real estate. The prior art seals that are formed by using techniques such as welding and soldering or by using o-rings can substantially bulk up the size of the package **100**. The hermetic seal **130** can be applied through simple in-line manufacturing processes. The prior art techniques of welding and soldering require very high temperature processes that are expensive, can damage the package, and occupy valuable real estate.

The hermetic seal **130** acts as an environmental barrier by blocking humidity and chemical contaminants from entering the package **100**. The hermetic seal **130** includes an adhesive mixed with an active component such as the zeolites. The adhesive alone, even a low permeation rate adhesive, cannot serve as a perfect environmental barrier because it eventually allows the contaminants and moisture to permeate. The active component can grab the contaminants and moisture that try to permeate into the package **100**, instead of merely blocking their entry. The active component can grab the contaminant gases that result from outgassing of the components **100** after the package **100** is formed. The active component can grab the portion of the adhesive that evaporates into the package **100** while the adhesive is curing. The thickness of the bead **130** and the amount of active component that is mixed with the adhesive can depend on the package **100** estimated life time and the estimated amount of contaminants and moisture that can penetrate the package **100** during the expected life time.

In some embodiments, an outer bead **150** of adhesive is applied around the perimeter of the bead **130**. The outer bead **150** can include a low permeation rate adhesive. The outer bead **150** can provide additional environmental protection to the package **100**. The outer bead can be useful for the aggressive environment in which the bead **130** alone cannot serve as an effective hermetic seal without being loaded with an impractical amount of the active component. If the bead **130** includes a very high portion of zeolites in the zeolites-adhesive mixture, for example more than sixty percent zeolites by weight, the bead **130** can become microscopically porous. The bead **130** can also become highly non-viscous and thus difficult to apply. Also, the bead **130** with a high percentage of zeolite by weight may not provide a robust mechanical support to the package **100**. In aggressive environments, the application of the outer bead **150** can slow down the penetration process of contaminants and moisture into the package **100**.

In the foregoing specification, the invention has been described with reference to specific exemplary embodiments thereof. It will, however, be evident that various modifications and changes may be made thereto without departing from the broader spirit and scope of the invention as set forth in the claims. The specification and drawings are, accordingly, to be regarded in an illustrative rather than a restrictive sense.

What is claimed is:

1. A micro-electromechanical systems [based] device [package] comprising:

a back plate glass;

a substrate glass;

at least one mirror located between the substrate glass and the back plate glass; the at least one mirror being configured to be actuated in an electronic display; and

[a bead of] an adhesive mixed with a zeolite, the adhesive applied between the back plate glass and the substrate glass; and, wherein the adhesive is applied substantially around the outer perimeter of the at least one mirror.

[a mirror processed on the substrate glass.]

2. The micro-electromechanical systems based device package of claim 1, including the bead being applied around the perimeter of the mirror.]

3. The micro-electromechanical systems [based] device [package] of claim 1, wherein the [bead] adhesive acts as a hermetic seal.

4. The micro-electromechanical systems [based] device [package] of claim 1, wherein the [bead] adhesive traps moisture and other contaminant gases that can be harmful to the mirror.

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[5. The micro-electromechanical systems based device package of claim 1, wherein the micro-electromechanical systems device includes an electronic display screen.]

6. A micro-electromechanical systems [based] (MEMS) device [package] comprising:

a back plate glass;

a substrate glass;

at least one MEMS structure located between the substrate glass and the back plate glass; and

[a bead of] an adhesive mixed with zeolites of different pore sizes, the adhesive applied between the back plate glass and the substrate glass, wherein the zeolites of different pore sizes are selected to absorb molecules of different diameters, wherein the adhesive is applied substantially around the outer perimeter of the at least one MEMS structure.

7. The micro-electromechanical systems [based] device [package] of claim 6, wherein some of the zeolites have a pore size to allow absorption of molecules having a diameter of up to ten angstroms.

8. The micro-electromechanical systems [based] device [package] of claim 6, wherein some of the zeolites have a pore size to allow absorption of molecules having a diameter of less than two angstroms.

9. The micro-electromechanical systems [based] device [package] of claim 6, wherein the pore sizes of some of the zeolites allow absorption of nitrogen and carbon dioxide molecules.

10. A micro-electromechanical systems [based] (MEMS) device [package] comprising:

a back plate glass;

a substrate glass;

at least one MEMS structure located between the substrate glass and the back plate glass, the at least one MEMS structure being configured to be actuated; and

[a bead of] an adhesive mixed with a zeolite, the adhesive applied between the back plate glass and the substrate glass, wherein the zeolite is selected to have a pore size which allows the zeolite to absorb a contaminant gas that is outgassed by [components of the package] the at least one MEMS structure, and wherein said pore size is up to about fifty Angstroms, wherein the adhesive is supplied substantially around the outer perimeter of the at least one MEMS structure.

11. The micro-electromechanical systems [based] device [package] of claim 10, wherein the zeolite has a pore size that allows it to absorb aromatic branched-chain hydrocarbons.

12. The micro-electromechanical systems [based] device [package] of claim 10, wherein the zeolite has a pore size that allows it to absorb hydrogen molecules.

13. The micro-electromechanical systems [based] device [package] of claim 10, wherein the zeolite has a pore size that allows it to absorb nitrogen and carbon dioxide molecules.

14. A micro-electromechanical systems (MEMS) device, comprising:

a back plate;

a substrate;

at least one reflective MEMS device located between the substrate glass and the back plate glass; and

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an adhesive mixed with a zeolite, the adhesive applied between the back plate and the substrate, wherein the zeolite is selected to absorb contaminant molecules outgassed by the at least one MEMS device, said contaminant molecules having a diameter of up to about ten angstroms, and wherein the adhesive is applied substantially around the outer perimeter of the at least one MEMS device.

15. The micro-electromechanical systems device of claim 14, wherein the zeolite is selected to absorb molecules having a diameter less than about two angstroms.

16. The micro-electromechanical systems device of claim 14, wherein the zeolite is selected to have a pore size between about two and three angstroms.

17. The micro-electromechanical systems device of claim 14, wherein the zeolite is selected to absorb aromatic branched-chain hydrocarbons.

18. The micro-electromechanical systems device of claim 14, wherein the zeolite is selected to absorb hydrogen molecules.

19. The micro-electromechanical systems device of claim 14, wherein the zeolite is selected to absorb moisture molecules.

20. A micro-electromechanical systems device, comprising:

a back plate;

a substrate;

at least one mirror located between the substrate and the back plate, the at least one mirror being configured to be actuated; and

an adhesive mixed with a zeolite, the adhesive applied between the back plate and the substrate, wherein the zeolite is selected to have a pore size of about fifty angstroms, and wherein the adhesive is applied substantially around the outer perimeter of the at least one mirror.

21. The micro-electromechanical systems device of claim 20, wherein the zeolite is selected to absorb nitrogen.

22. The micro-electromechanical systems device of claim 20, wherein the zeolite is selected to absorb carbon dioxide.

23. The micro-electromechanical systems device of claim 1, wherein the adhesive is applied as a bead between the back plate glass and the substrate glass.

24. The micro-electromechanical systems device of claim 6, wherein the adhesive is applied as a bead between the back plate glass and the substrate glass.

25. The micro-electromechanical systems device of claim 6, wherein the adhesive acts as a hermetic seal.

26. The micro-electromechanical systems device of claim 10, wherein the adhesive is applied as a bead between the back plate glass and the substrate glass.

27. The micro-electromechanical systems device of claim 10, wherein the adhesive acts as a hermetic seal.

28. The micro-electromechanical systems device of claim 1, wherein the at least one mirror comprises a plurality of mirrors, and wherein the adhesive is applied substantially around the perimeter of the plurality of mirrors.

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